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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Papasouliotis, George D.; Schravendijk, Bart van; Tas, Robert D.; Van  
Cleemput, Patrick A.  
Assignee: Novellus Systems, Inc.  
Title: Process For Depositing F-Doped Silica Glass In High Aspect Ratio  
Structures  
Application No.: 10/035,773 Filing Date: December 21, 2001  
Examiner: Unassigned Group Art Unit: 1745  
Docket No.: M-5091-2P US

Newport Beach, California  
April 1, 2002

BOX IDS  
COMMISSIONER FOR PATENTS  
Washington, D.C. 20231

INFORMATION DISCLOSURE STATEMENT  
UNDER 37 CFR § 1.97(b)

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Dear Sir:

Pursuant to 37 C.F.R. § 1.56, § 1.97 and § 1.98, the documents listed on the accompanying form PTO-1449 are called to the attention of the Examiner for the above patent application. In accordance with 37 C.F.R. § 1.98(d)(1), copies of the references can be found in Application Nos. 09/630,876, filed August 2, 2000, and 09/053,554, filed April 1, 1998. It is respectfully requested that the cited references be expressly considered during the prosecution of this application, and the references be made of record therein and appear among the "references cited" on any patent to issue therefrom.

Copies of the cited references can be submitted upon request.

Copies of these documents are enclosed.

Citation of these documents shall not be construed as:

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1. an admission that the documents are necessarily prior art with respect to the instant invention;
2. a representation that a search has been made, other than as described above; or
3. an admission that the information cited herein is, or is considered to be, material to patentability as defined in § 1.56(b).

Applicants believe that no fee is required for submission of this statement since it is submitted before the first office action. However, If a fee is required, the Commissioner is authorized to deduct such fee from the undersigned's Deposit Account No. 19-2386. Please deduct any additional fees from, or credit any overpayment to, the above-noted Deposit Account.

EXPRESS MAIL LABEL NO:

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Respectfully submitted,

Tom Chen  
Attorney for Applicant(s)  
Reg. No. 42,406

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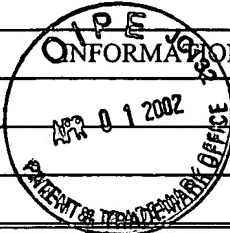
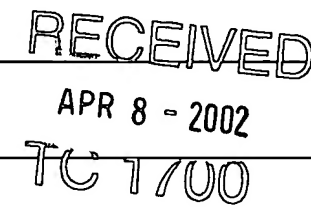
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U.S. Department of Commerce, Patent and Trademark Office					Atty Docket No.		Serial No.	
 INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use several sheets if necessary)					M-5091-2P US		10/035,773	
					Applicant(s)			
					Filing Date		Group	
					December 21, 2001		1745	
U.S. Patent Documents								
*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate	
	AA	5,872,058	02/99	Van Cleemput et al.				
	AB	5,571,576	11/05/96	Qian et al.	427	574		
	AC	5,641,712	06/24/97	Grivna et al.	438	624		
	AD	5,621,241	04/15/97	Jain	257	632		
	AE	5,376,211	12/94	Harada et al.	156	345		
	AF	5,270,264	12/14/93	Andideh et al.	437	228		
	AG	5,160,405	11/3/92	Miyauchi et al.	156	643		
	AH	5,118,384	06/02/92	Harmon et al.	156	643		
	AI	4,937,094	06/26/90	Doehler et al.				
	AJ	4,882,299	11/21/89	Freeman et al.	437	233		
	AK	4,264,409	04/28/01	Forget et al.	156	643		
	AL	3,741,886	06/28/71	Urbanek et al.	204	298		
Foreign Patent Documents								
							Translation	
		Document	Date	Country	Class	Subclass	Yes	No
	AM							
	AN							
	AO							
	AP							
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)								
	AQ	<div style="text-align: right;">  </div>						
	AR							
	AS							
Examiner			Date Considered					
*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.								